



Mansoura University	Faculty of Engineering	Electronics & Comm. Dept.	
Mid-Term Exam - 4 th - Year		Total Marks [30]	
28/11/2015	Optical Communication Systems	4 pages	Time: 1.5 Hour
Name		Sec	

Q1. Estimate one of the following relations

[5 marks]

sec (2) → Energy values for Hydrogen atom by solving Schrödinger equation

sec (4) → The density of states $\rho_{e,v}(E)$ for bulk semiconductor materials

Solution of Q1

$$E = E_K + E_P$$

$$= \frac{1}{2}mv^2 + \left(-\frac{e^2}{4\pi\epsilon_0 r} \right)$$

Solution of Schrodinger:

$$\psi(x) = e^{jkx}$$

→ The Function is periodic every λ

$$\therefore \psi(x) = \psi(x+\lambda)$$

$$e^{jkx} = e^{jkx} \cdot e^{jk\lambda}$$

$$\therefore k\lambda = n(2\pi) \quad n=1,2,3,\dots$$

$$\boxed{k = \frac{2\pi n}{\lambda}}$$

$$\therefore \lambda = 2\pi r \rightarrow \boxed{k = \frac{n}{r}} \rightarrow \textcircled{1}$$

→ De-Broglie Relation:

$$p = \hbar k = \frac{\hbar n}{r}$$

$$pr = \hbar n$$

$$mv \cdot r = \hbar n$$

$$v = \frac{\hbar n}{mr} \rightarrow \textcircled{2}$$

→ Coulomb's Force:

$$F = \frac{e^2}{4\pi\epsilon_0 r^2} \rightarrow \textcircled{3}$$

$$F = m \cdot a = m \frac{v^2}{r}$$

$$V^2 = \frac{e^2}{4\pi\epsilon_0 r m} \rightarrow \textcircled{5}$$

$$\text{Eqn (2) Power 2: } V^2 = \frac{\hbar^2 n^2}{mr^2}$$

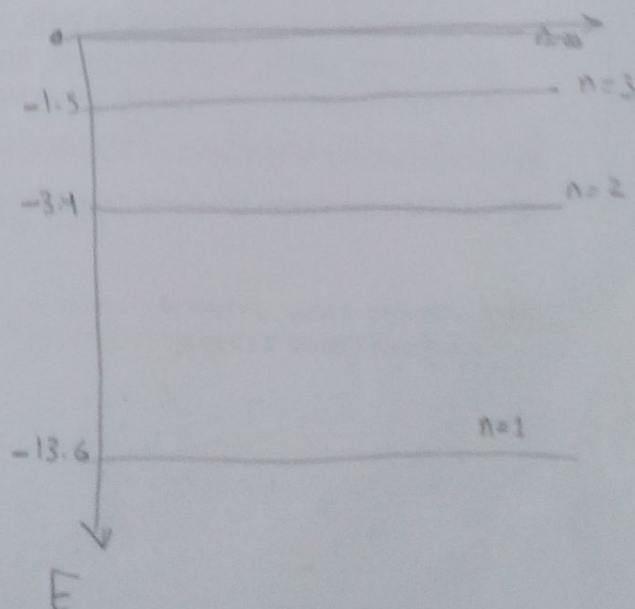
$$\therefore r = \frac{\hbar^2 n^2 \cdot 4\pi\epsilon_0}{me^2} = \frac{\hbar^2 n^2 \epsilon_0}{\pi m e^2} \rightarrow \textcircled{6}$$

$$\therefore \boxed{V = \frac{e^2}{2\hbar n \epsilon_0}}$$

$$E_K = \frac{1}{2}mv^2 = \frac{e^4 m}{8\hbar^2 n^2 \epsilon_0^2} \rightarrow \textcircled{I}$$

$$E_P = \frac{-e^2}{4\epsilon_0 \hbar^2 n^2}$$

$$E = \frac{-e^4 m}{8\hbar^2 n^2 \epsilon_0^2} = \frac{-13.6 \text{ eV}}{n^2}$$



[2 marks]

Q2. Compare between

- Materials: $\text{Al}_{0.1}\text{Ga}_{0.9}\text{As}$ and $\text{Al}_{0.7}\text{Ga}_{0.3}\text{As}$ (direct energy bandgap E_g type- application)
- Structures: N-GaAs/ N- $\text{Al}_{0.2}\text{Ga}_{0.8}\text{As}$, N-Si/ P-Si (Type of junction)

Solution of Q2

Materials	Direct Energy Bandgap E_g	Type of Material Bandgap	Application
$\text{Al}_{0.1}\text{Ga}_{0.9}\text{As}$	$E_g = 1.424 + 1.247x$ 1.55	Direct	optical sensor
$\text{Al}_{0.7}\text{Ga}_{0.3}\text{As}$	$E_g = 1.424 + 1.247x$ $+ 1.147(x-0.45)^2$ 2.37	Indirect	photo detector

Structures	Junction
N-GaAs/ N- $\text{Al}_{0.2}\text{Ga}_{0.8}\text{As}$	Isotype N-Hetero Junction
N-Si/ P-Si	Homo Junction

Q3. Cubic structure with 1mm side length and is made from intrinsic material with characteristics defined at room temperature 300 K as shown below. [17 marks]

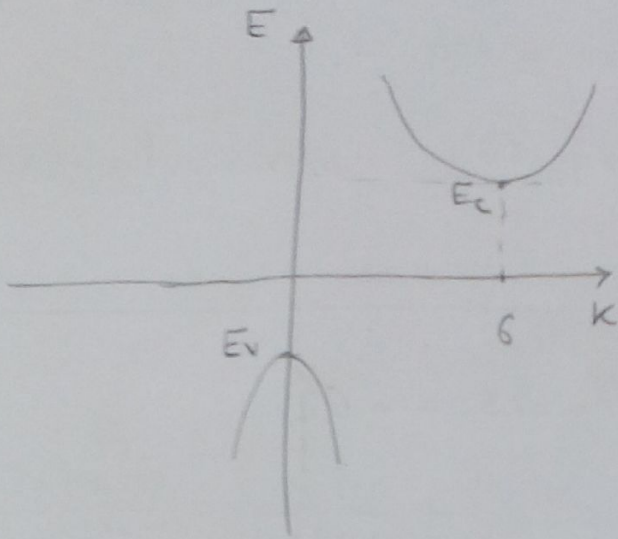
- E_2 (energy value in the conduction band) $= E_c + \frac{\hbar^2 (K-6)^2}{2m_c}$, $E_c = 48.9 \text{ eV}$, $m_c = 0.98m_0$ → curved ↓
- E_1 (energy value in the valence band) $= E_v + \frac{\hbar^2 K^2}{2m_v}$, $E_v = -50 \text{ eV}$, $m_v = 0.49m_0$

- Draw qualitatively the E-K diagram and determine the energy bandgap E_g and cutoff wavelength, comment on the mobility of carriers (μ_e and μ_h), determine whether the material has direct or indirect bandgap.
- Draw qualitatively the density of state curves for conduction and valence bands and calculate the intrinsic carrier concentrations. Redraw qualitatively the density of state curves when the dimensions of the structure have been changed to $1\text{mm} \times 1\text{mm} \times 10\text{\AA}$.
- Calculate the probabilities of finding electrons at $E = 48 \text{ eV}$ and holes at $E = -51 \text{ eV}$.
- Calculate the Fermi level energy E_f . How to modify the Fermi level energy?

Hint: Electron charge, $q = 1.6 \times 10^{-19} \text{ coulombs}$, $m_0 = 9.1 \times 10^{-31} \text{ kg}$, Boltzmann's constant $K = 1.38 \times 10^{-23} \text{ JK}^{-1}$, reduced Planck's constant $\hbar = 1.05 \times 10^{-34} \text{ Js}$.

Solution of Q3

E-K Diagram



$$\text{Energy band-gap} = E_c - E_v = -48.9 - (-50) = 1.1 \text{ eV}$$

$$\text{Cutoff wavelength} = \frac{1.24}{E_g} = \frac{1.24}{1.1} = 1.127 \mu\text{m}$$

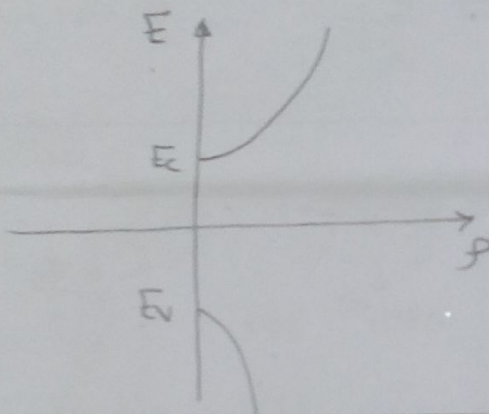
Comment on carriers mobility $\mu \propto \frac{1}{m^*}$
 $m_c > m_v$

\therefore Mobility of electrons in C.B. < smaller than holes in V.B.

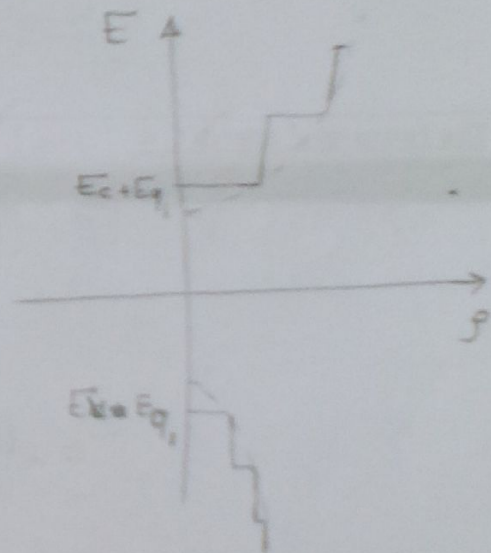
Determine whether the material has direct or indirect bandgap

Indirect BandGap

Density of states for 1mm×1mm×1mm structure



Density of states for 1mm×1mm×10A structure.



Intrinsic carrier concentration =

$$n_i = (N_c \cdot N_v)^{1/2} e^{-E_g/2KT}$$

$$N_c = 2 \left(\frac{0.98 \cdot 9.1 \cdot 10^{-31} \cdot 1.38 \cdot 10^{-23} \cdot 300}{2\pi (1.05 \cdot 10^{-34})^2} \right)^{3/2}$$

$$= 2.4 \cdot 10^{25} \text{ m}^{-3}$$

$$N_v = 2 \left(\frac{0.49 \cdot 9.1 \cdot 10^{-31} \cdot 1.38 \cdot 10^{-23} \cdot 300}{2\pi (1.05 \cdot 10^{-34})^2} \right)^{3/2}$$

$$= 8.7 \cdot 10^{24} \text{ m}^{-3}$$

$$n_i = \sqrt{(8.7 \cdot 10^{24} \cdot 2.4 \cdot 10^{25})} \cdot e^{-(1.1/0.025)}$$

$$= 4 \cdot 10^{15} \text{ m}^{-3}$$

$$= 4 \cdot 10^9 \text{ cm}^{-3}$$

The probability of finding electrons at $E = -48 \text{ eV} =$

$$E_F = \frac{E_C + E_V}{2} + \frac{3}{4} kT \ln\left(\frac{m_v}{m_c}\right)$$

$$(E - E_F)/kT = (-48 + 49.45)/0.025 = 58$$

$$P(E) = \frac{1}{e^{(E-E_F)/kT} + 1} = e^{-58} = 6 \times 10^{-26} \leftarrow \text{approximately zero}$$

The probability of finding holes at $E = -51 \text{ eV} =$

$$(E - E_F)/kT = (-51 + 49.45)/0.025 = -62$$

$$1 - P(E) = 1 - \frac{1}{e^{(E-E_F)/kT} + 1} = 1 - \frac{1}{e^{-62} + 1} = \frac{e^{-62} + 1 - 1}{e^{-62} + 1} = \frac{e^{-62}}{e^{-62} + 1} \leftarrow \text{approximately zero}$$

The Fermi level energy $E_F =$

$$E_F = \frac{-48.9 - 50}{2} + \frac{3}{4} kT \ln\left(\frac{m_v}{m_c}\right)$$

$\begin{matrix} \uparrow & \uparrow \\ 1.38 \times 10^{-23} & 300 \end{matrix}$

$$= -49.45 - (2.15 \times 10^{-21}) = -49.45$$

The Fermi level energy can be modified by Doping

Good Luck!

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